	Application No.	Applicant(s)
Interview Summary	10/618,219	BAO ET AL.
interview Summary	Examiner	Art Unit
	George A. Goudreau	1763
All participants (applicant, applicant's representative, PTO	personnel):	,
(1) examiner George A. Goudreau.	(3)	
(2) attorney Daniel R McClure.	(4)	
Date of Interview: <u>03 October 2005</u> .		
Type: a)⊠ Telephonic b)□ Video Conference c)□ Personal [copy given to: 1)□ applicant	2)⊠ applicant's representative	
Exhibit shown or demonstration conducted: d) Yes If Yes, brief description:	e)⊠ No.	
Claim(s) discussed: claims of record.		
Identification of prior art discussed: art of record.		
Agreement with respect to the claims f)⊠ was reached. (	g) was not reached. h) h	I/A.
Substance of Interview including description of the general reached, or any other comments: <u>The attorney for applicant by the examiner.</u> The attorney for applicant agreed to sup Tawain being a WTO member, etc. in order to vacate the process.	nt called the examiner to discu ply additional documentation to	ss the final rejection issued the examiner regarding
(A fuller description, if necessary, and a copy of the amend allowable, if available, must be attached. Also, where no callowable is available, a summary thereof must be attached.	copy of the amendments that w	
THE FORMAL WRITTEN REPLY TO THE LAST OFFICE A INTERVIEW. (See MPEP Section 713.04). If a reply to the GIVEN ONE MONTH FROM THIS INTERVIEW DATE, OR FORM, WHICHEVER IS LATER, TO FILE A STATEMENT Summary of Record of Interview requirements on reverse s	e last Office action has already THE MAILING DATE OF THE OF THE SUBSTANCE OF TH	been filed, APPLICANT IS S INTERVIEW SUMMARY
·		
•		
	GEÖF PRIM	Ponge A Joudnau IGE GOUDREAU ARY EXAMINER
Examiner Note: You must sign this form unless it is an		23-051
Attachment to a signed Office action.	Examiner's sign	ature, if required

### Summary of Record of Interview Requirements

Manual of Patent Examining Procedure (MPEP), Section 713.04, Substance of Interview Must be Made of Record

A complete written statement as to the substance of any face-to-face, video conference, or telephone interview with regard to an application must be made of record in the application whether or not an agreement with the examiner was reached at the interview.

## Title 37 Code of Federal Regulations (CFR) § 1.133 Interviews Paragraph (b)

In every instance where reconsideration is requested in view of an interview with an examiner, a complete written statement of the reasons presented at the interview as warranting favorable action must be filed by the applicant. An interview does not remove the necessity for reply to Office action as specified in §§ 1.111, 1.135. (35 U.S.C. 132)

37 CFR §1.2 Business to be transacted in writing.

All business with the Patent or Trademark Office should be transacted in writing. The personal attendance of applicants or their attorneys or agents at the Patent and Trademark Office is unnecessary. The action of the Patent and Trademark Office will be based exclusively on the written record in the Office. No attention will be paid to any alleged oral promise, stipulation, or understanding in relation to which there is disagreement or doubt.

The action of the Patent and Trademark Office cannot be based exclusively on the written record in the Office if that record is itself incomplete through the failure to record the substance of interviews.

It is the responsibility of the applicant or the attorney or agent to make the substance of an interview of record in the application file, unless the examiner indicates he or she will do so. It is the examiner's responsibility to see that such a record is made and to correct material inaccuracies which bear directly on the question of patentability.

Examiners must complete an Interview Summary Form for each interview held where a matter of substance has been discussed during the interview by checking the appropriate boxes and filling in the blanks. Discussions regarding only procedural matters, directed solely to restriction requirements for which interview recordation is otherwise provided for in Section 812.01 of the Manual of Patent Examining Procedure, or pointing out typographical errors or unreadable script in Office actions or the like, are excluded from the interview recordation procedures below. Where the substance of an interview is completely recorded in an Examiners Amendment, no separate Interview Summary Record is required.

The Interview Summary Form shall be given an appropriate Paper No., placed in the right hand portion of the file, and listed on the "Contents" section of the file wrapper. In a personal interview, a duplicate of the Form is given to the applicant (or attorney or agent) at the conclusion of the interview. In the case of a telephone or video-conference interview, the copy is mailed to the applicant's correspondence address either with or prior to the next official communication. If additional correspondence from the examiner is not likely before an allowance or if other circumstances dictate, the Form should be mailed promptly after the interview rather than with the next official communication.

The Form provides for recordation of the following information:

- Application Number (Series Code and Serial Number)
- Name of applicant
- Name of examiner
- Date of interview
- Type of interview (telephonic, video-conference, or personal)
- Name of participant(s) (applicant, attorney or agent, examiner, other PTO personnel, etc.)
- An indication whether or not an exhibit was shown or a demonstration conducted
- An identification of the specific prior art discussed
- An indication whether an agreement was reached and if so, a description of the general nature of the agreement (may be by
  attachment of a copy of amendments or claims agreed as being allowable). Note: Agreement as to allowability is tentative and does
  not restrict further action by the examiner to the contrary.
- The signature of the examiner who conducted the interview (if Form is not an attachment to a signed Office action)

It is desirable that the examiner orally remind the applicant of his or her obligation to record the substance of the interview of each case. It should be noted, however, that the Interview Summary Form will not normally be considered a complete and proper recordation of the interview unless it includes, or is supplemented by the applicant or the examiner to include, all of the applicable items required below concerning the substance of the interview.

A complete and proper recordation of the substance of any interview should include at least the following applicable items:

- 1) A brief description of the nature of any exhibit shown or any demonstration conducted,
- 2) an identification of the claims discussed,
- 3) an identification of the specific prior art discussed,
- 4) an identification of the principal proposed amendments of a substantive nature discussed, unless these are already described on the Interview Summary Form completed by the Examiner,
- 5) a brief identification of the general thrust of the principal arguments presented to the examiner,

(The identification of arguments need not be lengthy or elaborate. A verbatim or highly detailed description of the arguments is not required. The identification of the arguments is sufficient if the general nature or thrust of the principal arguments made to the examiner can be understood in the context of the application file. Of course, the applicant may desire to emphasize and fully describe those arguments which he or she feels were or might be persuasive to the examiner.)

- 6) a general indication of any other pertinent matters discussed, and
- 7) if appropriate, the general results or outcome of the interview unless already described in the Interview Summary Form completed by the examiner.

Examiners are expected to carefully review the applicant's record of the substance of an interview. If the record is not complete and accurate, the examiner will give the applicant an extendable one month time period to correct the record.

### **Examiner to Check for Accuracy**

If the claims are allowable for other reasons of record, the examiner should send a letter setting forth the examiner's version of the statement attributed to him or her. If the record is complete and accurate, the examiner should place the indication, "Interview Record OK" on the paper recording the substance of the interview along with the date and the examiner's initials.

### **PATENT**

### IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:

Confirmation Number: 4415

Tien-I Bao

Group Art Unit: 1763

Serial No.: 10/618,219

Examiner: Goudreau, George A.

Filed: July 10, 2003

TKHR Docket No. 252011-1390

Top-Team Ref. 0503-7148US

For: METHOD FOR PREVENTING FORMATION OF PHOTORESIST SCUM

### **COMMUNICATION WITH EXAMINER GOUDREAU**

Mail Stop Amendment Assistant Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Examiner Goudreu:

This submission is made in follow-up to our teleconference of yesterday, and is further to the previous submissions made in this application.

### Taiwan is a WTO Member

First, you indicated that you needed me to submit proof that Taiwan is a member to the WTO. Attached is a 5-page printout from the WTO web site (see <a href="www.wto.org">www.wto.org</a>), which lists all 148 member countries. Taiwan is identified under the name of "Chinese Taipei." In this regard, I have also attached one page from the accession document for Chinese Taipei (also obtained from the WTO web site) evidencing that "Chinese Taipei" includes the Separate Customs Territory of

Taiwan (among others). This should be sufficient to evidence Taiwan's membership in the WTO, and therefore enable inventors from Taiwan to submit declarations under 37 CFR 1.131.

### Declaration under 37 CFR 1.131

Also attached is a declaration, which was previously executed by the inventors. I did not submit this with the last response, as I did not believe it was necessary. However, a copy is now provided for your reference. This alone should be sufficient to overcome the outstanding rejections.

Further, it is my understanding that the cited published application should be removed from consideration, as it does not constitute prior art under 35 USC 102(e) or 103, in that the subject matter that was disclosed (but not claimed) in the published application (and which is claimed in the present application) was invented by the inventors of the present application. As such, the published application does not constitute an invention "by another." Further still, at the time the present invention was made, the inventors were under a duty to assign to the assignee of the published application.

For at least the foregoing reasons, Applicants believe that Notice of Allowance is warranted. At your request, this submission is being made to your private facsimile number (571-273-1434) If I need to formally submit this to facsimile number (571) 273-8300 or by mail, please let me know.

No fee is believed to be due in connection with this amendment and response to Office Action. If, however, any fee is believed to be due, you are hereby authorized to charge any such fee to deposit account No. 20-0778.

Respectfully submitted,

By:

Daniel R. McClure Registration No. 38,962

Thomas, Kayden, Horstemeyer & Risley, LLP 100 Galleria Pkwy, NW Suite 1750 Atlanta, GA 30339 770-933-9500

search



TRADE

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UNDERSTANDING THE WTO: THE ORGANIZATION

### Members and Observers



148 members on February 2005, with dates of membership.

Click any member to see key information on trade statistics, WTO commitments, disputes, trade policy reviews, and notifications.

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9	Least-developed countries list
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Albania 8 September 2000	<b>④</b> 1
Angola 23 November 1996	
Antigua and Barbuda 1 January 1995	Clic
Argentina 1 January 1995	info
Armenia 5 February 2003	con
Australia 1 January 1995	rev
Austria 1 January 1995	
Bahrain, Kingdom of 1 January 1995	
Bangladesh 1 January 1995	\$ee > Hc
Barbados 1 January 1995	> W
Belgium 1 January 1995	> <u>Le</u>
Belize 1 January 1995	<u>cl</u> .
Benin 22 February 1996	> <u>Cc</u>
Bolivia 12 September 1995	<u>or</u>
Botswana 31 May 1995	<u>st</u> .
Brazil 1 January 1995	
Brunei Darussalam 1 January 1995	
Bulgaria 1 December 1996	
Burkina Faso 3 June 1995	
Burundi 23 July 1995	
Cambodia 13 October 2004	
Cameroon 13 December 1995	•
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Congo 27 March 1997	
Costa Rica 1 January 1995	
Côte d'Ivoire 1 January 1995	
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<u>Cuba</u> 20 April 1995	
Cyprus 30 July 1995	
Czech Republic 1 January 1995	

Democratic Republic of the Congo 1 January

1997

<u>Denmark</u> 1 January 1995 <u>Djibouti</u> 31 May 1995

**Dominica** 1 January 1995

Dominican Republic 9 March 1995

Ecuador 21 January 1996

**Egypt 30 June 1995** 

El Salvador 7 May 1995

Estonia 13 November 1999

European Communities 1 January 1995

Fiji 14 January 1996

Finland 1 January 1995

Former Yugoslav Republic of Macedonia

(FYROM) 4 April 2003

France 1 January 1995

Gabon 1 January 1995

The Gambia 23 October 1996

Georgia 14 June 2000

Germany 1 January 1995

Ghana 1 January 1995

Greece 1 January 1995

Grenada 22 February 1996

Guatemala 21 July 1995

Guinea 25 October 1995

Guinea Bissau 31 May 1995

Guyana 1 January 1995

Haiti 30 January 1996

Honduras 1 January 1995

Hong Kong, China 1 January 1995

Hungary 1 January 1995

Iceland 1 January 1995

India 1 January 1995

Indonesia 1 January 1995

Ireland 1 January 1995

Israel 21 April 1995

Italy 1 January 1995

Jamaica 9 March 1995

Japan 1 January 1995

<u>Jordan</u> 11 April 2000

Kenya 1 January 1995

Korea, Republic of 1 January 1995

Kuwait 1 January 1995

Kyrgyz Republic 20 December 1998

Latvia 10 February 1999

Lesotho 31 May 1995

<u>Liechtenstein</u> 1 September 1995

Lithuania 31 May 2001

Luxembourg 1 January 1995

Macao, China 1 January 1995

Madagascar 17 November 1995

Malaw1 31 May 1995

Malaysia 1 January 1995

Maldives 31 May 1995

Mali 31 May 1995

Malta 1 January 1995

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Mexico 1 January 1995

Moldova 26 July 2001

Mongolia 29 January 1997

Morocco 1 January 1995

Mozambique 26 August 1995

Myanmar 1 January 1995

Namibia 1 January 1995

Nepal 23 April 2004

Netherlands - For the Kingdom in Europe and

for the Netherlands Antilles 1 January 1995

New Zealand 1 January 1995

Nicaragua 3 September 1995

Niger 13 December 1996

Nigeria 1 January 1995

Norway 1 January 1995

Oman 9 November 2000

Pakistan 1 January 1995

Panama 6 September 1997

Papua New Guinea 9 June 1996

Paraguay 1 January 1995

Peru 1 January 1995

Philippines 1 January 1995

Poland 1 July 1995

Portugal 1 January 1995

Qatar 13 January 1996

Romania 1 January 1995

Rwanda 22 May 1996

Saint Kitts and Nevis 21 February 1996

Saint Lucia 1 January 1995

Saint Vincent & the Grenadines 1 January

1995

Senegal 1 January 1995

Sierra Leone 23 July 1995

Singapore 1 January 1995

Slovak Republic 1 January 1995

Slovenia 30 July 1995

Solomon Islands 26 July 1996

South Africa 1 January 1995

Spain 1 January 1995

Sri Lanka 1 January 1995

Suriname 1 January 1995

Swaziland 1 January 1995

Sweden 1 January 1995

Switzerland 1 July 1995

Chinese Taipei 1 January 2002

Tanzania 1 January 1995

Thailand 1 January 1995

Togo 31 May 1995

Trinidad and Tobago 1 March 1995

Tunisia 29 March 1995

Turkey 26 March 1995

Uganda 1 January 1995

United Arab Emirates 10 April 1996
United Kingdom 1 January 1995
United States of America 1 January 1995
Uruguay 1 January 1995
Venezuela (Bolivarian Republic of)
1 January 1995
Zambia 1 January 1995

### Observer governments back to top

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**Bahamas** 

Belarus

Bhutan

Bosnia and Herzegovina

Zimbabwe 5 March 1995

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Ethiopia

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<u>lran</u>

Iraq

Kazakhstan

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Lebanese Republic

Libya

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**Russian Federation** 

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Sao Tomé and Principe

Saudi Arabia

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<u>Seychelles</u>

Sudan

<u>Tajikistan</u>

**Tonga** 

Ukraine

Uzbekistan

Vanuatu

Viet Nam

<u>Yemen</u>

Note: With the exception of the Holy See, observers must start accession negotiations within five years of becoming observers.

### International intergovernmental

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contact us: World Trade Organization, rue de Lausanne 154, CH-1211 Geneva 21, Switzerland

## WORLD TRADE

7709510933

## **ORGANIZATION**

RESTRICTED WT/ACC/TPKM/18 5 October 2001

(01-4741)

Working Party on the Accession of Chinese Taipci

> REPORT OF THE WORKING PARTY ON THE ACCESSION OF THE SEPARATE CUSTOMS TERRITORY OF TAIWAN, PENGHU, KINMEN AND MATSU

#### I. INTRODUCTION

- At its meeting on 29 September-1 October 1992, the GATT 1947 Council of Representatives established a Working Party, as perfected in the respective Minutes (document C/M/259), to examine the application of the Separate Customs Territory of Taiwan, Penghu, Kinmen and Matsu (hereinafter referred to a "Chinese Taipei") to accede to the General Agreement 1947 under Article XXXIII, and to submit to the Council recommendations which may include a Draft Protocol of Accession. Membership of the Working Party was open to all contracting parties wishing to serve on it. Following the request of Chinese Taipei, circulated in document WT/ACC/TPKM/1, and pursuant to the decision of the General Council of 31 January 1995, the Working Party was transformed into a World Trade Organization (WTO) Working Party to negotiate the terms of accession of Chinese Taipei to the Marrakesh Agreement Establishing the World Trade Organization (hereinafter referred to as the "WTO Agreement") under Article XII of that Agreement.
- The Working Party met on 6 November 1992, 15 April 1993, 28 June 1993, 12 October 1993, 17 May 1994, 26 July 1994, 21 December 1994, 28 February 1997, 8 May 1998, 12 May 1999, and 18 September 2001 under the Chairmanship of H.E. Mr. M. Morland (United Kingdom). The terms of reference and the membership of the Working Party are set out in document WT/ACC/TPKM/6/Rev.6.

#### INFORMATION PROVIDED IJ.

The Working Party had before it, to serve as a basis for its discussion, the memorandum on Chinese Taipei's foreign trade regime (L/7097 and Addenda 1-11) and the questions submitted by Members on the foreign trade regime of Chinese Taipci together with the replies of the Chinese Taipei authorities thereto (L/7089/Rev.1, L/7429 and Add.1), and documents Spec(94)28 (Newly Promulgated or Revised Laws and Regulations), Spec(94)30 (Description of Service Sectors), Spec(94)31 and Add.1 (Special Exchange Agreement), Spec(94)41 (Status Report of the Bilateral Negotiations), Spec(95)1 and Corr.1 (Checklist of Accession Issues - Preliminary Responses Provided by Chincse Taipei), Spec(95)8 (Laws and regulations regarding agricultural products), WT/ACC/TPKM/2 (Tariff reductions for 758 tariff lines effected as from 14 July 1995), WT/ACC/TPKM/3 (Newly Promulgated or Revised Laws and Regulations), and WT/ACC/TPKM/4 (The Customs Import Tariff and Classification of Import and Export Commodities: revised edition of August 1995); WT/ACC/TPKM/8/Rev.2 and WT/ACC/TPKM/9/Rev.2 (Information on Industrial Subsidies); WT/ACC/TPKM/10 (Adoption of WT/ACC/TPKM/12 (Standards for Agricultural and Processed Agricultural Codex Standards); WT/ACC/TPKM/13 (List of Commodities Subject to Export Restriction and List of Commodities); WT/ACC/TPKM/14 and Corr.1 and Add.1 (Additional Questions and Replies Concerning Domestic Support and Export Subsidies). In addition, the representative of Chinese Taipei made available to the Working Party the following material:

c

### DECLARATION UNDER U.S.C. §1.131

- 1. We, Tien-I BAO, Shwang-Min JENG and Syun-Ming Jang, employees of Taiwan Semiconductor Manufacturing Company, are the inventors of the subject matter disclosed in Serial No. 10/618,219 (the "219 application").
- 2. We conceived the subject matter of the '219 application at least as early as December 12, 2000, on which date we filled out an invention disclosure form of the Taiwan Semiconductor Manufacturing Company, a copy of which is attached hereto as Exhibit A.
- 3. Upon information and belief, the invention disclosure form that described the subject matter of the '219 application was provided to the Taiwan Semiconductor Manufacturing Company legal department for the purpose of determining whether a patent application should be pursued.
- 4. Upon information and belief, the Taiwan Semiconductor Manufacturing Company legal department regularly and periodically reviews invention disclosure forms that are submitted for the purpose of determining whether patent applications should be prepared and filed.
- 5. Upon information and belief, it was determined that a patent application should be prepared and filed based upon our invention disclosure and that the invention disclosure was referred to outside counsel for preparation of a patent application.
- 6. Upon information and belief, this application was prepared through the cooperative effort of Daniel R. McClure and individuals of a patent firm in Taiwan.
- 7. The preparation of this application required a back-and-forth exchange of information, drafts, and comments, until the application was finalized for filing.

- 8. Upon information and belief, a copy of the formal declaration for the patent application was provided to the Taiwan Semiconductor Manufacturing Company legal department by June 13, 2003 under cover letter of declaration for patent application and power of attorney. (Exhibit C)
- 9. On June 13, 2003, we reviewed the final draft of the patent application and signed the formal declaration, which was then returned to Daniel R. McClure for filing with the U.S. Patent and Trademark Office (U.S.P.T.O).
- 10. Upon information and belief, the patent application that is now identified as the '219 application was filed with the U.S.P.T.O. on July 10, 2003.

We hereby declare: (a) that all statements made herein of our own knowledge are true; (b) that all statements made on information and belief are believed to be true; (c) that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code; and (d) that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

Tien-I BAO

Date: 17/13/2004

Date: 10/17/2004

Syun-Ming JANG

Date: 12/13/04

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# tsmc台灣積體電路

### TSMC INVENTION DISCLOSURE

EMP. NO.	FULL NAME(S) OF INVENTOR(S)		DEPT.	DEPT. CODE	TEL. NO.	SECURITY B TSMC-RESTRICTED
	ENGLISH Ex: Da-Tung Lee	CHINESE Ex: 季大周				FOR USE BY PATENT AFFAIRS DEPARTMENT
0096C4	Tien-1 Bao	型	CFT	2321	17033586	DISCLOSURE NO.:
008774	Lain-long Li	<b>奉</b> 通忠	150	2331	7033460	TSMC01cap-0855
006931	Shwang-Ming Jang	\$KGE-55	7.FD	2331	7033457	RECEIVED DATE:
003815	Syun-Ming Jeng	起動明	TFD	2331	7033458	(Time Stamp)
			i			13/2-2000
	1	1			i	

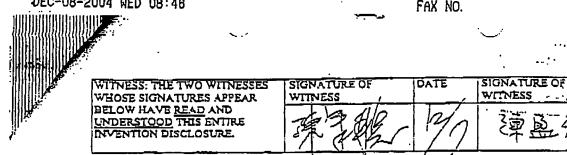
- TITLE OF INVENTION (ENGLISH ONLY)
  ENGLISH—METHODS TO RESOLVE LIVOU PR SCUM IN VIA AFTER TRECH
  PHOTO DEVELOPMENT
- BACKGROUND INFORMATION CURRENT PRACTICE AND DISADVANTAGES (ENGLISH ONLY)
   In via first Cu damasecne process, NHx (amine) redicals in etch stop (SiN, SiC), and ARL (SiON) films causes PR soum in via after trench photo development.
- MAIN POINTS OF CLAIM (PLEASE LIST ITEM BY ITEM: 利用师题方法/ 手段绘制主体) (ENGLISH ONLY)
  - 1. Non-amine or amine barrier for each stop, ARL to prevent amine redicals diffusion into low K IMD.
- FROBLEM SOLVED OR IMPROVEMENTS OBTAINED BY THIS INVENTION (PLEASE LIST ITEM BY ITEM) (ENGLISH ONLY)
  - I. PR scum in via can be largely improved.
- KEYWORD SEARCH FOR PATENT/LITERATURES (ENGLISH ONLY)
  PR SQUM
- PATENT/ LITERATURES SEARCH RESULT (PLEASE SPECIFY SEMILAR PATENT NO. AND LITERATURE CITATION) (ENGLISH ONLY)
  No similar found
- DETAIL DESCRIPTION OF INVENTION (ENGLISH ONLY)

PR soum in via after trench photo development is a serious problem in CL013 (and below) LowK/Cu process. NHx (amine) based redicals interact with PR is the key mechanism. How to eliminate or block amine redical in IMD becomes one possible solution. There are two amine sources in lowK/Cu damascene IMD deposition. One is etch stop layer, SiN or SiCN, another is anti-reflection layer (ARL) SiON. Here anounce several non amine or amine barrier materials to resolve PR soun.

For etch stop, ARL and barrier: SiOx PECVD using silicon source gases: SiH4. Si2H6, SiF4, TEOS, alkyl-silane (alkyl= methyl, ethyl, propyl..) and oxida : gases: O2, CO2, CO, H2O, H2O2 and carrier gases: Ar, He, CH4 mixtuer, spin-on glass, BARC...

Scheme: 1. Etch stop/lowK IMD/barrier/ARL 2. Etch stop/barrier/lowK IMD/barrier/ARL 3. Etch stop/lowK IMD/ARL 4. Etch stop/barrier/LowK IMD/ARL 4. Etch stop/barrier/LowK IMD/ARL 4.

SECURITY B



DISCLOSURE SUBMITTED BY				
INVENTORS' EMPNO	INVENTORS' NAME	INVENTOR'S SIGNATURE D	ATE	
009604	包天一	セスー	12/7	
008774	李運忠	<b>冷</b> 運岩	12/17	
006931	<b>突壁</b> 给	如 教	12/7	
003816	章動明	学型内	1.2/7	
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## tsmc台灣積體電路

### TSMC INVENTION DISCLOSURE

EMP. NO.	FULL NAME(S) OF INVENTOR(S)		DEPT. DEPT. CODE	TEL. NO.	SECURITY B TSMC-RESTRICTED	
:	ENGLISH Ex: Da-Tung Lee	CHINE5E Ex: 班大同				FOR USE BY PATENT AFFAIRS DEPARTMENT
009604	Tim-1 Buo	2大一	<b>एना</b>	222!	17833586	DISCLOSURE NO.:
003774	i نحا ang Li	李皂忠	TFO	2331	7033460	TSMC11cap-=855
006931	Shwang-Ming Jeng	鈴樊鎔	TFD	2331	7033457	RECEIVED DATE:
003815	Syun-Ming Jang	章動明	TFD	2331	7033458	(TIME STAMP)
						13/2-2000

- TITLE OF INVENTION ENGLISH ONLY)
   ENGLISH METHODS TO RESOLVE LK/CU PR SCUM IN VIA AFTER TRECH
   PHOTO DEVELOPMENT
- BACKGROUND INFORMATION CURRENT PRACTICE AND DISADVANTAGES (ENGLISH ONLY)
   In via first Cu damasecne process, NHx (amine) redicals in etch stop (SiN, SiC), and ARL (SiON) films causes PR soum in via after trench photo development.
- MAIN POINTS OF CLAIM (PLEASE LIST ITEM BY ITEM: 利用师硕方法/ 军路领制主约) (ENGLISH ONLY)
  - 1. Non-amine or amine barrier for each stop, ARL to prevent amine redicals diffusion into low K IMD.
- PROBLEM SOLVED OR IMPROVEMENTS OBTAINED BY THIS INVENTION (PLEASE LIST ITEM BY ITEM) (ENGLISH ONLY)
  - 1. PR scum in via can be largely improved.
- KEYWORD SEARCH FOR PATENTALITERATURES (ENGLISH ONLY)
  PR south
- PATENT/ LITERATURES SEARCH RESULT (PLEASE SPECIFY SIMILAR PATENT NO. AND LITERATURE CITATION) (ENGLISH ONLY)
   No similar found
- DETAIL DESCRIPTION OF INVENTION (ENGLISH ONLY)
  PR scurn in via after trench photo development is a serious problem in CL013 (and below) LowK/Cu process. NHx (amine) based redicals interact with PR is the key mechanism. How to eliminate or block amine redical in IMD becomes one possible solution. There are two amine sources in lowK/Cu damascene IMD deposition. One is etch stop layer, SiN or SiCN, another is anti-reflection layer (ARL) SiON. Here anounce several non amine or amine barrier materials to resolve PR scurn.

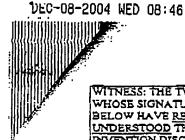
For etch stop, ARL and barrier: SiOx PECVD using silicon source gases: SiH4, Si2H6, SiF4, TEOS, alkyl-silane (alkyl= mothyl, ethyl, propyl..) and oxida it gases: O2, CO2, CO, H2O, H2O2 and carrier gases: Ar, He, CH4 mixtuer, spin-on glass, BARC...

Scheme: 1. Etch stop/lowK IMD/barrier/ARL 2. Etch stop/barrier/lowK IMD/barrier/ARL 3. Etch stop/lowK IMD/ARL 4. Etch stop/barrier/LowK IMD/ARL ATTACHMENTS:

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008774	李運思	李遵宏	12/7	
006931	鄭學銘	TO Ra EX	12/7	
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